PARADEMARM OF PPLIC

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

PPLICANTS:

Martin HOHEISEL et al.

CONF. NO.: 5214

SERIAL NO.:

10/655,025

GROUP: 2882

FILED:

September 5, 2003

EXAMINER: Allen C. Ho

FOR:

METHOD FOR PRODUCING AND APPLYING AN

ANTISCATTER GRID OR COLLIMATOR TO AN X-RAY OR

GAMMA DETECTOR

COMMENTS ON EXAMINER'S STATEMENT OF REASONS FOR ALLOWANCE

Customer Service Window
Randolph Building
401 Dulany Street
Alexandria, VA 22314
Mail Stop Issue Fee

November 3, 2006

Dear Sir:

The Examiner offers reasons why the claims of the present application are allowable over the prior art of record. Although Applicants agree that the various claimed limitations mentioned in the claims are not taught or suggested by the prior art taken either singly or in combination, Applicants wish to emphasize that it is the language of each claim taken individually, including the interrelationships and interconnections between various claimed elements, which is allowable over the prior art of record.

For example, with regard to claim 1, the Examiner emphasizes that the prior art fails to teach or fairly suggest a basic structure produced by layer-wise solidification by using a rapid prototyping technique. *Notice of Allowance*, p. 2. Applicants agree that

this feature is not taught or fairly suggested by the prior art; however, Applicants wish to emphasize that it may be this feature alone and/or in combination with all other features of claim 1 that distinguishes claim 1 over the prior art of record.

Similar reasoning applies to each of claims 2-34.

Respectfully submitted,

HARNESS, DICKEY & PIERCE, PLC

Bv

Donald J. Daley Reg. No. 34,313

DJD/AMW:jcp

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